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(71) Applicant: ALNAIR LABS:KK

NATIONAL INSTITUTE OF  
ADVANCED INDUSTRIAL &  
TECHNOLOGY

(72) Inventor: SAKAKIBARA YOICHI

TOKUMOTO MADOKA

KATAURA HIROMICHI

ACHINAMI HIROTSUGU

TANAKA YUICHI

MARK KENNETH ZHABORONSKI

SZE YUN SET

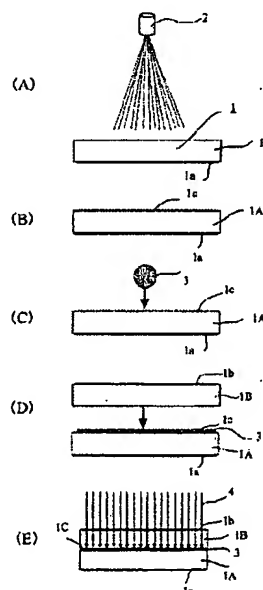
## (54) SATURABLE ABSORPTION CHIP, ITS MANUFACTURING METHOD, AND DEVICE USING SATURABLE ABSORPTION CHIP

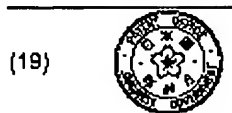
### (57) Abstract:

**PROBLEM TO BE SOLVED:** To solve the problems with saturable absorption chips constituted by using carbon nanotubes that the chips are in a mechanically brittle state and have the structure inadequate for mass production and to improve saturable absorption.

**SOLUTION:** The invention comprises reinforcing the structure which is heretofore mechanically brittle by using two sheets of optical materials. In combination, the saturable absorption chips which are made suitable for mass production by using such optical materials and are provided with the chip structure having the stable saturable absorption characteristics to suppress reflection loss, the method for manufacturing the same and the saturable absorption device using the saturable absorption chips are included.

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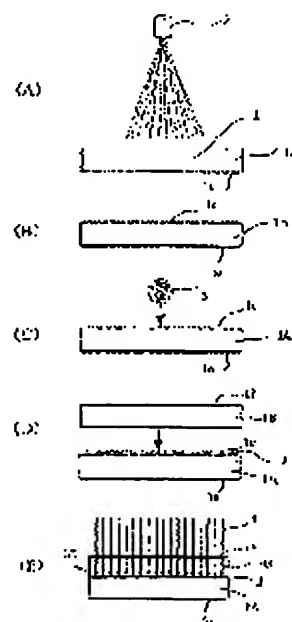
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**NATIONAL INSTITUTE OF**  
**ADVANCED INDUSTRIAL &**  
**TECHNOLOGY**  
(72) Inventor: **SAKAKIBARA YOICHI**  
**TOKUMOTO MADOKA**  
**KATAURA HIROMICHI**  
**ACHINAMI HIROTSUGU**  
**TANAKA YUICHI**  
**MARK KENNETH ZHABORO**  
**SZE YUN SET**(54) **SATURABLE ABSORPTION CHIP, ITS  
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TOKUMOTO MADOKA;  
KATAURA HIROMICHI;  
ACHINAMI HIROTSUGU;  
TANAKA YUICHI;  
MARK KENNETH ZHABORONSKI;  
SZE YUN SET;**⌘ Assignee:** ALNAIR LABS:KK  
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**⌘ IPC Code:** [G02F 1/355](#); [C03C 27/12](#);**⌘ Priority Number:** 2003-03-13 JP2003000112145**⌘ Abstract:** PROBLEM TO BE SOLVED: To solve the problems with saturable absorption chips constituted by using carbon nanotubes that the chips are in a mechanically brittle state and have the structure inadequate for mass production and to improve saturable absorption.

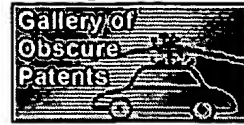
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**⌘ Family:** None**⌘ Other Abstract** None  
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